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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/625,409	07/23/2003	Yasuyuki Unno	00684.002700.2	9928	
5514	7590 12/22/2004		EXAM	EXAMINER	
FITZPATRIC	CK CELLA HARPER &	KIM, PE	KIM, PETER B		
30 ROCKEFE			ARTIBUT	DADED MUDADED	
NEW YORK,	NY 10112		ART UNIT	PAPER NUMBER	
			2851	2851	
			DATE MAILED: 12/22/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/625,409	UNNO, YASUYUKI				
Office Action Summary	Examiner	Art Unit				
	Peter B. Kim	2851	And I			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence addr	ess			
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	within the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONEI	ely filed s will be considered timely. the mailing date of this comr (35 U.S.C. § 133).	nunication.			
Status						
1) Responsive to communication(s) filed on	_•					
2a) ☐ This action is FINAL . 2b) ☒ This	action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	3 O.G. 213.				
Disposition of Claims						
4) Claim(s) 11-13 is/are pending in the application	1					
4a) Of the above claim(s) is/are withdraw						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>11-13</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9)☐ The specification is objected to by the Examiner						
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correcti	on is required if the drawing(s) is obj	ected to. See 37 CFR	1.121(d).			
11) The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO	-152.			
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau 	s have been received. s have been received in Application ity documents have been receive	on No. <u>09/123,443</u> .	age			
* See the attached detailed Office action for a list of the certified copies not received.						
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Attachment(s) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
Notice of References Cited (PTO-692) Notice of Draftsperson's Patent Drawing Review (PTO-948) Notice of Draftsperson's Patent Drawing Review (PTO-948) Notice of References Cited (PTO-692) Notice of References Cited (PTO-692)	Paper No(s)/Mail Da 5) Notice of Informal Pa	te	52)			

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 11-13 are rejected under 35 U.S.C. 102(e) as being anticipated by Kim et al. (Kim) (6,057,970).

Kim discloses a projection exposure apparatus (Fig. 3) and method comprising an illumination system (20) for illuminating a reticle (30), a projection optical system form projection a pattern (Fig. 3) comprising a plurality of lenses that cause birefringence (some birefringence is inherent to all lenses), at least one optical element for eliminating the birefringence (210) wherein the at least one optical element is detachably mounted on the projection optical system (200 is a separate unit of the optical system). The step of developing the exposed wafer is inherent to all the method of manufacturing a device using a projection exposure apparatus.

Claims 11-13 are rejected under 35 U.S.C. 102(e) as being anticipated by Ophey et al. (Ophey) (5,694,247).

Ophey discloses a projection exposure apparatus (Fig. 8, col. 7, line 53 – col. 9, line 15) and method comprising an illumination system (A) for illuminating a reticle (B), a projection optical system form projection a pattern (C) comprising a plurality of lenses that cause

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birefringence (4), at least one optical element for eliminating the birefringence (5) wherein the at least one optical element is detachably mounted on the projection optical system (5, abstract).

The step of developing the exposed wafer is inherent to all the method of manufacturing a device using a projection exposure apparatus.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Peter B. Kim whose telephone number is (571) 272-2120. The examiner can normally be reached on 8:00 AM - 5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Judy Nguyen can be reached on (571) 272-2258. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Peter B. Kim Primary Examiner

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